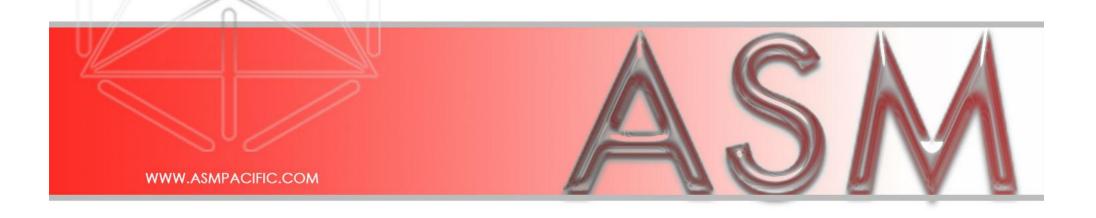
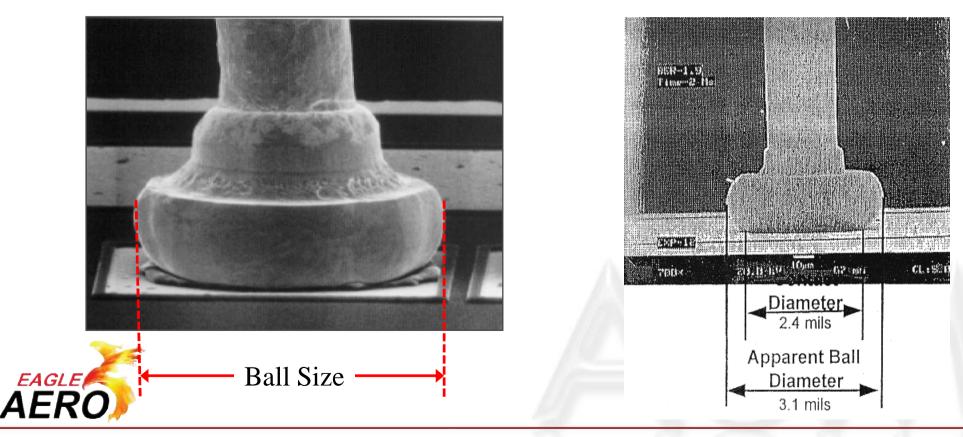
Cu Bonding Quality Guidelines Confirmation





p Ball Size

- n Ball Size is measured base on the Apparent Ball Diameter
- **n** Max Ball Size \leq BPO 5 um
- n Recommended Ball Size = Capillary Chamfer Diameter x 1.2

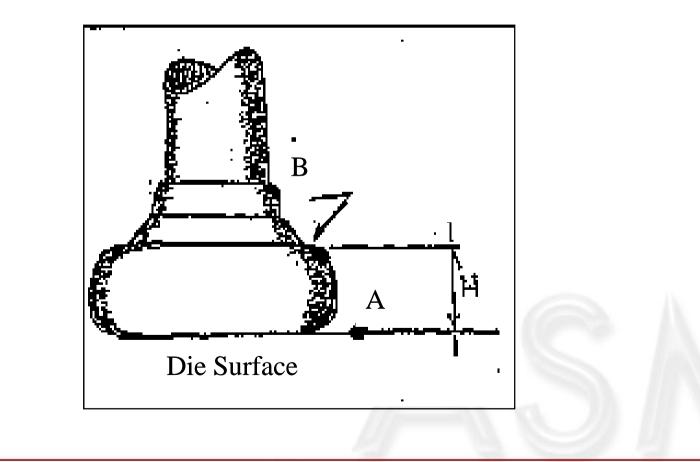


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p Ball Height

- n Ball Height is measured from Die Surface (A) to lowest capillary contact point (B)
- **n** Recommended Ball Height = Wire Diameter x 0.5

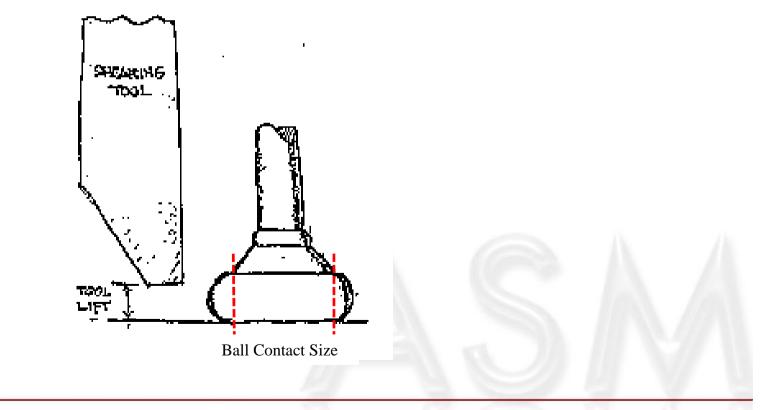






p Ball Shear

- n Ball Shear is the destructive test to measure 1st Bond bonding strength
- n Recommended shear tool height is 1/3 of ball height
- n Ball Shear reading is calculated per Ball Contact Area
- **n** Recommended Ball Shear \geq 8 gram/mil²





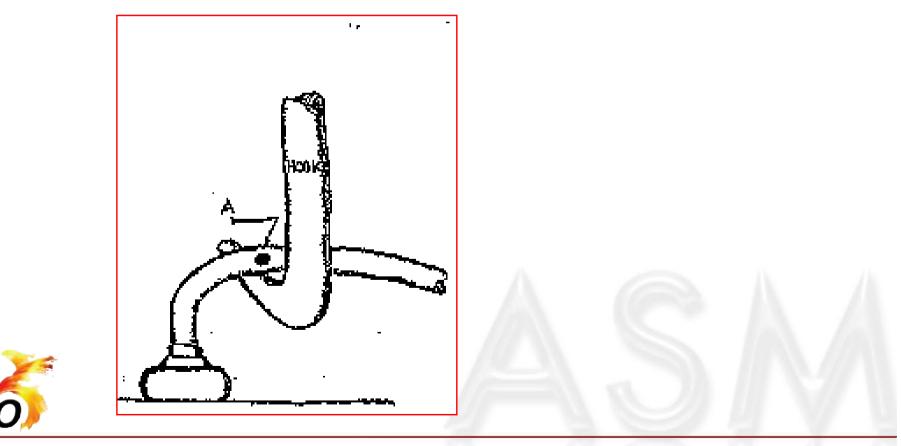


p Wire Pull

EAGLE

AEI

- n Wire Pull is a destructive test to measure bonding strength and inspect failure mode
- n Wire Pull is perform by placing the pull hook under the wire close to 1st bond





P Wire Pull Reject Criteria

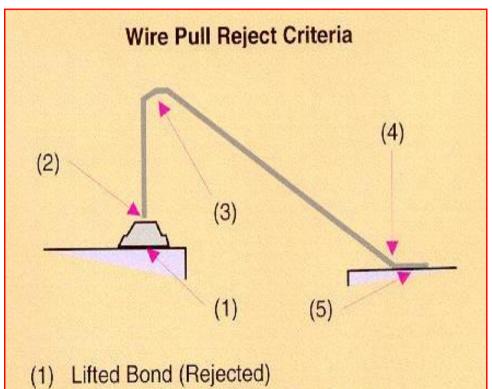
- n Ball Lift and Peeling is not acceptable
- n Break at neck to compare with wire pull spec to determine neck strength





Lifted Bond with Ball Lift

Lifted Bond with Peeling



- (2) Break at neck (Refer wire-pull spec)
- (3) Break at wire (Refer wire-pull spec)
- (4) Break at stitch (Refer to stitch-pull spec)
- (5) Lifted weld (Rejected)



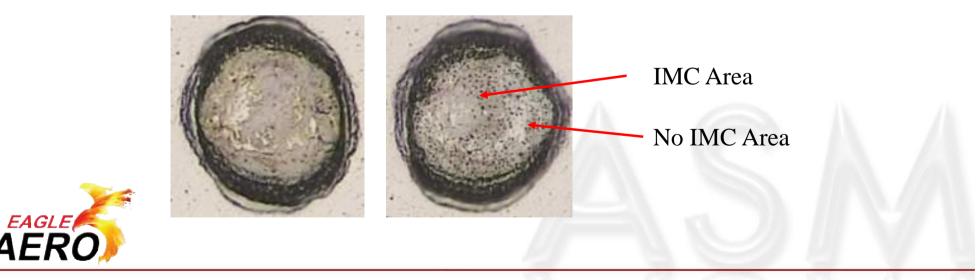


p IMC Check

n To check the IMC coverage of the bonded package

n Procedure:

- p Heat bonded package under heater block with 200°C for 60mins
- p Drop a few drop of Nitric Acid (HNO3) on pad surface for 5 15 seconds
- p Clean with DI Water
- **p** Dry with air gun and measure under high power scope
- **n** Recommended IMC coverage \geq 80%
- n Not prefer to have non-IMC area cluster together





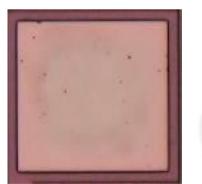
p Cratering Test

- n To check if bonded ball penetrate the Al layer and damage the Si layer
- **n** Procedure:
 - **p** Drop a few drop of Nitric Acid (HNO3) on pad surface for 5 15 seconds
 - p Clean with DI Water (This is to remove the Cu Wire)
 - P Drop a few drop of Aqua Regia (HCI+HNO3) on pad surface for 5 15 seconds
 - p Clean with DI Water (This is to remove the Al layer)
 - **p** Dry with air gun and measure under high power scope
- **n** No cratering must be found on pad surface





Crack is visible on pad surface



No crack is found on pad surface